



Supplemental Figure 1) SEM images of conformal Te ALD coated trenches using a TeO₂ nucleation seed layer: (a) shows the full 250 nm wide, 24:1 aspect ratio trenches, (b) shows a magnified image of the top of the trench, (c) shows the middle of the trench ~3μm from top, and (d) shows the bottom of the trench.